

***IN THE UNITED STATES PATENT AND TRADEMARK OFFICE***

Applicant: Crocker et al.  
Title: Nanometer-Scale Engineered Structures,  
Methods and Apparatus for Fabrication thereof,  
and Applications to Mask Repair,  
Enhancement, and Fabrication  
Appl. No.: 10/689,547  
Filing Date: 10/21/2003  
Examiner: Ruggles  
Art Unit: 1756

**TRANSMITTAL OF CORRECTED FORMAL REPLACEMENT FIGURES**


Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Transmitted herewith are the corrected formal replacement figures (1-2 sheets, Figures 19 and 21) in response to the Examiner's objection in the above-identified application. Applicants submit that the attached replacement figures overcome the objections raised by the Examiner in the January 19, 2007 office action.

..... Respectfully submitted, .....

Date June 4, 2007

By 

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